

PATENT

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D.C.
8-28-01

Date: May 8, 2001

PRELIMINARY AMENDMENT

Prior to the examination of the above application, please amend the above-identified application as follows. Attached hereto is a marked up version of the changes made to the claims by the current amendment. The marked up version of the changes to the claims is captioned **“Version With Markings To Show Changes Made”**.

Please insert the following text on page 1, line 1:

The present application claims priority to Japanese Patent Application No. 2000-139537 filed May 12, 2000, the disclosure of which is incorporated herein by reference in its entirety. -

Please delete Claims 5-8 for the purposes of rewriting.

9. A resist material according to claim 1 wherein said or more surfactants having a fluorine substituent is selected from the group consisting of perfluoroalkylpolyoxyethylene ethanol, fluorinated alkyl ester,